

ULTRA-HIGH VACUUM IN SCIENTIFIC RESEARCH

Unmatched Flexibility and Pressure Range



Large Hadron Collider at CERN

Ultra-High Vacuum Drives Vital Scientific Research

Ultra-High Vacuum (UHV) conditions are a prerequisite for most complex research conducted by government labs, academia, and private industry.



National Laboratories, large global research universities, and industries such as defense, aerospace, and analytical instrument manufacturing utilize a wide range of vacuum equipment to achieve required levels of vacuum, and many of these organizations rely on Leybold for highly-specific vacuum pumps, instruments, and systems.

Unmatched Flexibility & Pressure Range

A pioneer in the field of scientific and industrial vacuum equipment for 170 years, **Leybold** is synonymous with scientific vacuum technology.

Our mission has always been to provide the scientific community with the tools that enable cuttingedge discovery and innovation. We offer our customers the most flexible range of vacuum equipment on the market, from roughing pumps to gauges to custom UHV equipment.

A One-Stop Solution

From offering a single vacuum pump to custom-designing highly complex, modular UHV systems, Leybold is the go-to partner of research scientists and physicists around the globe.



Working range of different vacuum technologies offered by Leybold.

special operating range



Take a Look into the Future

Giant telescopes like the ones used at Mauna Kea Observatory in Hawaii, the Instituto de Astrofisica in the Canary Islands, and the European Southern Observatory in Chile rely on their flawless mirrors whose reflective coatings would not be possible without vacuum technology provided by Leybold.



Leybold's Equipment in Action

Our systems can be found in material sciences, optical coatings, high-energy physics, surface analytics, and nuclear research environments that require High to Ultra-High Vacuum conditions. These areas include Particle Accelerators, Gravitational Wave Detectors, Synchrotrons, and Large Space Simulators (LSS).

Ultra-High Vacuum Applications:

- Surface Analysis
- High-Energy Physics
- Molecular Beam Epitaxy (MBE)

High Vacuum Applications:

- Thin-Film Deposition
- Nuclear Physics
- Space Simulations
- Analytical Instruments



High-Energy Physics/National Laboratories

Leybold's vacuum equipment plays a pivotal role in sustaining the vacuum needs of all National Laboratories in the United States, as well as many others around the globe.

We work with physicists across the world to design and customize vacuum systems for particle accelerators, enabling them to bring their ideas to life.

For example, CERN—one of the world's most celebrated accelerators—relies on vacuum conditions created by Leybold's vacuum pumps. Leybold continues to push the boundaries of innovation to deliver cutting-edge pumps, gauges, leak detectors, and complete systems.



Material Science

The most critical aspect of advanced materials development research is the ability to analyze and characterize material properties at atomic and molecular level. A continuous research effort is devoted to gradually replace empiricism with robust computational strategies derived on the basis of the fundamental understanding of materials. Surface science in particular is capable of providing this fundamental information because of the advent of a multitude of novel surface characterization techniques.

Surface analytical tools operating under ultra-high vacuum conditions can characterize materials with respect to composition, crystallographic, and electronic structure.



Aerospace/Space Research

Space research laboratories around the globe rely on technology provided by Leybold for qualification of mission-critical applications.

Space simulation chambers are systems used to recreate the environmental conditions that spacecraft experience in space. They also serve to qualify components and materials used in spacecraft. Space simulation chambers are capable of analyzing system behavior, evaluating thermal balance, and verifying functionalities to ensure mission success and survivability.

Modular Ultra-High Vacuum Platforms

From simple standardized offerings to complex customized systems, Leybold's M-UHV Platforms facilitate a wide range of research and analysis techniques that require ultra-high vacuum conditions.

The highly versatile turn-key set-up, multi-flanged confocal chamber and the UHV transfer station allows for virtually endless experimental possibilities.

M-UHV Platform Capabilities

Sample preparation procedures including ion sputtering, annealing over 1000 K, substrate cooling under 100K, precursor or adsorbate dosing, etc.

Ultimate System Pressure < 1 x 10⁻¹⁰ mbar

A wide range of UHV surface analysis techniques, including:

- X-Ray Photoelectron Spectroscopy (XPS)
- Auger Electron Spectroscopy (AES)
- Scanning Electron Microscopy (SEM)
- Low Energy Electron Diffraction (LEED)
- Scanning Tunneling Microscopy (STM)
- Ultra-violet Photoelectron Spectroscopy (UPS)
- Temperature Programmed Disorption (TPD)
- Scanning Auger Micoscropy (SAM)
- Secondary Ion Mass Spectroscopy (SIMS)



Thin-Film Growth & Preparation Techniques, including:

- Molecular Beam Epitaxy (MBE)
- UHV Chemical Vapor Deposition (CVD)
- UHV Pulsed Laser Deposition (PLD)

Cluster Tool Assembled Using M-UHV Platforms



Leybold was instrumental in helping UNL customize a UHV cluster tool design. The combination of this tool with the attached femtosecond laser (FSLP) source is an extremely powerful setup and the only system of its kind in the United States.

Dr. Dennis Alexander, Kingery Engineering Professor

Customer Spotlight: The University of Nebraska-Lincoln

The University's Research Interest

UNL's research focuses on understanding the fundamental principles of laser interaction with surfaces i.e. light-matter interactions. UNL is particularly vested in studying ultra-fast lasers along with their applications and propagation of ultra-short femtosecond pulses.

The UNL & Leybold Partnership

One of the core areas of UNL's research involves surface structuring of materials using femtosecond lasers. Essentially, this results in generation of well-defined nanostructures rendering the surfaces with some very interesting properties including super-hydrophobicity, extremely high emissivity, anti-icing properties, and reduced drag. These aspects, once understood, will have a profound impact in the area of functional surfaces and interfaces.

UNL partnered with Leybold to develop a highly specialized UHV processing and surface analysis tool that was based on Leybold's Modular UHV Platforms product line.



A Flexible Solution for a Highly Complex Challenge

The state-of-the-art UHV cluster tool that resulted from the partnership with Leybold now resides in a university lab. While one section of the tool is used for laser processing of surfaces under UHV conditions, the other is used for atomic studies, molecular studies, and electron imaging of the processed surfaces. The combination of this tool with the attached femtosecond laser (FSLP) source is an extremely powerful setup and the only system of its kind in the United States.



UNL's FSLP system was configured using Leybold's M-UHV Platforms product line. The system was customized per customer specification and can be used for UHV processing and characterization utilizing a wide range of surface science techniques.

The specific experimental capabilities of the UHV cluster tool include precision substrate manipulation, x-ray photoelectron spectroscopy, auger electron spectroscopy, scanning electron microscopy, scanning auger microscopy, depth profiling and temperature desorption spectroscopy, all under ultra-high vacuum conditions.

Measurable Impact on UNL's Research Needs

Thanks to this new investigative capability, UNL is able to work on a wide array of projects with unique applications, including drag reduction, enhanced heat transfer, stem cell growth on surfaces, imparting surfaces with anti-icing properties, producing black metal surfaces with extremely high emissivity.



Product Line Overview

Leybold has been on the forefront of providing industry-leading vacuum pumps and equipment for 170 years. Our product line covers the entire spectrum of vacuum equipment, from basic roughing pumps to highly customized UHV systems.

Ultra-High & High Vacuum Systems

M-UHV Platforms

Modular Ultra-High Vacuum Experimentation Platforms

Automation Based Options Include

100 | 200 | 300 | 400

Ultimate Pressure

< 5 x 10⁻¹⁰ mbar

For more information on our M-UHV Platforms, please see Page 4.

- Substrate temperature variation from 100K - 1000K
- Accurate temperature measurement
- Modular concept along with UHV transfer station facilitates easy assembly of cluster systems
- Plug and play configuration for a wide range of UHV experimentation tools
- Incorporates flag-style sample holders



UNIVEX

Thin-Film Deposition and Experimentation Systems

Established range of experimental coating and thin-film deposition systems.

Size Based Options

UNIVEX 250 | 400 | 600 | 900

Ultimate Pressure

5 x 10⁻³ mbar

Other offerings in the UNIVEX series include:

UNIVEX G Glove box systems UNIVEX C Cluster tool systems **UNIVEX S** Space simulation systems **UNIVEX D** Dactyloscopy systems

Configurable for almost all vacuum

• Multiple deposition techniques in the

PVD coating processes

Cleanroom compatible

Ease of access and operation

same chamber



TiTan Ion Pumps

PUMPING SPEED OPTIONS Small Ion Pumps

Mini (0.2) | 3 | 10 | 25 | 45 | 75 l/s

Low Profile Ion Pumps

100 | 200 | 300 | 400 | 600 | 800 | 1200 l/s

Tall Profile Ion Pumps

150 | 300 | 600 l/s

Ultimate Pressure

<1 x 10⁻¹¹ mbar

Three Element Options

TiTan CV (Conventional) Two titanium cathodes for high pumping speed of reactive gases

TiTan DI (Differential)

Combination of titanium and tantalum cathodes for stable handling of reactive & noble gases

TiTan TR (Triode)

Classic triode element for handling noble gases and stable operation at higher pressures

BoostiVAC Titanium-Sublimation Pumps (TSP)

TSP H₂ Pumping Speed Options*

1600 - 12,000 l/s

*depends on implementation of recommended cryoshroud or ambient sputter shield

Ultimate Pressure

<1 x 10⁻¹¹ mbar

Non-Evaporable Getter (NEG)

NEG H₂ Pumping Speed Options

50 | 100 | 200 | 300 | 400 | 400 l/s

Ultimate Pressure

<1 x 10⁻¹¹ mbar

- Ultimate vacuum level in a short time
- Hydrocarbon-free, vibration-free vacuum conditions

Vibration-free ultra-high vacuum

Lowest possible vacuum level at lowest cost

Low maintenance, long operational life

· Extremely easy to implement and operate



Compact form factor

- High and uniform pumping speed
- Reactivated without venting to atmosphere







TURBOVAC i/iX Turbomolecular Pumps with Hybrid Bearing Technology

Helium Pumping Speed Options 90 | 250 | 350 | 450 | 850 | 950 I/s

Ultimate Pressure

8 x 10⁻⁸ mbar *(ISO-K/F variant)* 5 x 10⁻¹⁰ mbar *(CF variant)*

- Oil-free hybrid bearings
- Excellent light gas compression
- Easy to operate, compact design



TURBOVAC MAGINTEGRA Magnetically Levitated Turbomolecular Pumps

Pumping Speed Options

300 | 400 | 600 | 700 | 1300 | 1600 | 1700 | 2100 l/s

Ultimate Pressure

1 x 10⁻⁸ mbar *(ISO-K/F variant)* 1 x 10⁻¹⁰ mbar *(CF variant)*

- Absolutely hydrocarbon free
- Extremely low vibration
- Maintenance free



COOLVAC

Cryogenic Pumps

Pumping Speed Options

1500 | 2000 | 3000 | 5000 | 10000 | 18000 | 30000 | 60000 l/s

Ultimate Pressure

<1 x 10⁻¹¹ mbar

Basic options with remote electronics and/or baffles cooled using LN₂

- Hydrocarbon-free vacuum
- Completely automatic electric regeneration
- High capacity for argon and hydrogen



Fore Vacuum Pumps

DIVAC

Diaphragm Pumps

Pumping Speed Options Two-stage Pumps

0.6 | 1.2 | 2.2 m³/h

Ultimate Pressure

8 mbar

Three-stage Pumps

0.8 | 1.4 | 3.8 | 4.8 m³/h

Ultimate Pressure

0.5 – 3 mbar

- Dry compressing, oil-free pump
- Portable, compact, small footprint
- Excellent for backing turbomolecular pumps



SCROLLVAC plus Oil-free Scroll Pumps

Pumping Speed Options 7 | 10 | 15 | 18 m³/h Ultimate Pressure

9 x 10⁻³ mbar

- Robust design
- Low maintenance
- High pumping speed at atmosphere



ECODRY plus Dry Compressing Multi-Stage Roots Pumps

Pumping Speed Options

25 | 35 | 40 | 65 m³/h

Ultimate Pressure

3 x 10⁻² mbar

- Quietest pump in its class
- Oil and particulate free
- High water-vapor tolerance
- Excellent helium and hydrogen performance



VARODRY

Dry Compressing Screw Pumps

Pumping Speed Options

65 | 100 | 160 | 200 m³/h

Ultimate Pressure

1 x 10⁻² mbar

- Rust-free materials of construction
- Oil and particulate free
- Air cooled pumps



SCREWLINE DryCompressing Screw Pumps

Pumping Speed Options

630 m³/h

Ultimate Pressure

5 x 10⁻³ | 1 x 10⁻² mbar

- Possible to clean the pumps on-site
- Air cooled pumps
- Rust-free materials of construction



DRYVAC Dry Compressing Screw Pumps

Pumping Speed Options

300 | 450 | 650 | 1200 m³/h

Ultimate Pressure

5 x 10⁻³ mbar

- Oil-free pumping chamber
- Water cooled pumps
- Best-in-class energy consumption



SOGEVAC Single-Stage Oil Sealed Rotary Vane Pumps

Pumping Speed Options

10 | 16 | 25 | 28 | 40 | 65 | 100 | 120 | 200 | 300 | 630 m³/h

Ultimate Pressure

0.05 - 1.5 mbar* *depending on the pump sub-type

- High pumping speed also at low pressures
- Integrated exhaust filter
- Rugged design with optimum size-to-performance ratio



TRIVAC Two-Stage Oil Sealed Rotary Vane Pumps

Pumping Speed Options

2.5 | 4 | 8 | 16 | 25 | 40 | 65 | 90 m³/h

Ultimate Pressure

2 x 10⁻³ mbar

RUVAC

Roots Vacuum Pumps

WA/WAU series with air-cooled flange-mounted motors

Pumping Speed Options

251 | 501 | 1001 | 2001 m³/h

WS/WSU series with air-cooled canned motors

Pumping Speed Options

251 | 501 | 1001 | 2001 m³/h

WH/WHU series with water-cooled hermetically sealed motors

Pumping Speed Options

700 | 2500 | 4400 | 7000 m³/h

Ultimate Pressure

As low as 1 x 10^{-5} mbar possible.

- Extremely leak-tight (Helium capable)
- High water-vapor tolerance
- Pressure-lubricated sliding bearings



- Shift the operating pressure into the medium/ high vacuum range
- Enhanced pumping speed in combination with appropriate FV pumps
- Wide range of options to suit specific process requirements



Ancillary Products & Services

TURBOLAB

Turnkey Turbomolecular Pump Systems

Pumping Speed Options 90 | 250 | 350 | 450 l/s

Ultimate Pressure

- 5 x 10⁻¹⁰ mbar *(CF variant)*
- Completely preassembled plug-and-play system
- Compact mobile design, small footprint
- Built-in webserver for system



LEYSPEC

Residual Gas Analyzers

AMU Range-based Options

VIEW 100 | 200 with and without SEM option

ULTRA 200S | 300S

Min. Detectable Partial Pressure

1 x 10⁻¹⁴ mbar (View with SEM) 1 x 10⁻¹⁵ mbar (ULTRA with SEM)

- Excellent AMU Range
- Direct partial pressure display feature on the unit
- Ease of operation
 Differentially pumped cart system available



PHOENIX

Helium and Hydrogen Tracer Gas Leak Detection Systems

FV Pumping Based Options

Vario | Quadro | Cart Mounted Systems

- Vacuum and Sniffer (over pressure) leak detection capabilities
- Quick startup, measurement, and calibration process
- Wi-Fi accessible with any web enabled mobile device



COOLPOWER Coldheads

Pneumatically Driven Single Stage **50 |140i** Lowest Attainable Temperatures **26 K | 15 K**

Dual Stage 7/25i | 5/100i Lowest Attainable Temperatures 1st Stage 35K | 2nd Stage 10K Mechanically Driven

Single Stage 250 MDi

Lowest Attainable Temperatures 25K

Dual Stage **10 MDi** Lowest Attainable Temperatures **1st Stage 28 K | 2nd Stage 8K**

- Installation possible in any orientation
- Short cool down time with no liquid refrigerants required
- Highly reliable and extremely simple to operate
- On-site displacer changes



VACUUM MEASUREMENT Active Sensors		
CERAVAC Transmitters Capacitance Diaphragm Gauges Pressure Range Atm to 10 ⁻⁵ mbar	 Extremely accurate and reliable forevacuum pressure measurement Simple, cost and space-saving installation Smart monitoring and control 	CERAMO
THERMOVAC TransmittersThermal Conductivity GaugesSensor Type Based OptionsPirani CapacitanceDiaphragm-PiraniPressure RangeAtm to 10 ⁻⁵ mbar	 Simple, cost-effective and robust sensors Suited for heavily contaminated environments Smart monitoring and control 	TREMOLING CONTRACT OF CONTRACT
PENNINGVAC Sensors Cold Cathode Ionization Gauges Pressure Range Atm to 10 ⁻⁹ mbar	 Robust, easy-to-maintain design Excellent response time High reproducibility and high accuracy 	DEMINIOUND
IONIVAC Transmitters Hot Cathode Ionization and Pirani-based Combination Gauges Pressure Range Atm to 5 x 10 ⁻¹⁰ mbar	 Single transmitter covering 13 decades of pressure Simple, compact, rugged design in a metal housing Model with built-in display for stand-alone operation available 	

VACUUM MEASUREMENT Passive Sensors			
THERMOVAC Sensors Thermal Conductivity Gauges Pressure Range Atm to 5 x 10 ⁻⁴ mbar	 Cost-effective sensing cell Tungsten or platinum filament Fully aligned and temperature compensated 		
PENNINGVAC Sensors Cold Cathode Ionization Gauges Pressure Range 10 ⁻² to 10 ⁻⁹ mbar	 Robust, fast acting, easy to maintain Insensitive to air inrushes and vibrations Exchangeable cathode plate 		
IONIVAC Sensors Hot Cathode Ionization Gauges	 High accuracy due to individually calibrated sensing system 		620 •
Collector type based options Bayard-Alpert Extractor	 Suitable for most demanding applications 	Calles.	
	Bakeable models for radiation environment		
Pressure Range			
10 ⁻² to 2 x 10 ⁻¹¹ mbar (Bayard-Alp	ert)		
10 ⁻⁴ to 10 ⁻¹² mbar (Extractor)			
Hardware, Valves and Fitting	JS		

From atmosphere to UHV, Leybold also offers a complete range of valves, hardware, and fittings with all possible flange types.

- Almost every connection possible to facilitate constructions of any vacuum system
- Support with design and selection
- All components are subjected to helium leak testing



Please see Leybold's catalog for complete product details.





Leybold Offers a One-Stop Solution

From replacing a single vacuum pump to custom designing highly complex, modular UHV systems, Leybold is the go-to partner of research scientists and physicists around the globe.

Leybold's product line also features a complete range of vacuum pump flanges and fittings. For more details on our entire line of vacuum equipment and ancillary products, please download our product catalog.





Image descriptions, from top left to bottom right: Particle Accelerator; Mauna Kea Observatory in Hawaii; Large Hadron Collider at CERN; Satellite in Orbit; Scientist Examining a Component Fabricated Using Advanced Metal Alloy.



Pioneering products. Passionately applied.